AMENDMENTS TO THE CLAIMS

The listing of the claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

1. (withdrawn) A micropyrolyzer for vaporization of a liquid or solid sample, comprising:

a substrate having a suspended membrane formed thereon, the membrane having a top side facing the substrate for accepting the sample; and a resistive heating element disposed on the membrane such that the sample will be vaporized upon heating of the membrane by the resistive heating element.

- 2. (withdrawn) The micropyrolyzer of claim 1 wherein the substrate is selected from the group consisting of semiconductors and dielectrics.
- 3. (withdrawn) The micropyrolyzer of claim 2, wherein the substrate comprises silicon.
- 4. (withdrawn) The micropyrolyzer of claim 1, wherein the membrane comprises a material selected from the group consisting of silicon nitride, polysilicon, silicon oxynitride and silicon carbide.
- 5. (withdrawn) The micropyrolyzer of claim 1, wherein the resistive heating element comprises a circuitous metal trace.
- 6. (withdrawn) The micropyrolyzer of claim 1, wherein the metal comprises a metal selected from the group consisting of platinum, molybdenum, titanium, chromium, palladium, gold, tungsten, and combinations thereof.
- 7. (currently amended) A method for vaporizing a liquid or solid sample for analysis, comprising:
 - a) providing a micropyrolyzer, comprising:

a substrate having a suspended membrane formed thereon, the membrane having a surface for accepting the sample; and

a resistive heating element disposed on the membrane;

- b) depositing the sample on the sample-accepting surface of the membrane;
- c) heating the sample on the membrane with the resistive heating element to form a vapor; and
- d) removing the vapor from the micropyrolyzer for chemical analysis of the vapor.
- 8. (currently amended) The method of claim 7, further comprising the step of introducing a reagent chemical to the sample prior to step c).
- 9. (original) The method of claim 7, wherein the sample size is less than 3 microliters.
- 10. (original) The method of claim 7, wherein the sample heating rate is greater than 20°C per millisecond.
- 11. (original) The method of claim 7, wherein the sample heating rate is greater than 40°C per millisecond.
- 12. (original) The method of claim 7, wherein the sample heating rate is greater than 60°C per millisecond.
- 13. (original) The method of claim 7, wherein the sample can be heated to a temperature of up to 1000°C.
- 14. (original) The method of claim 7, wherein the heating requires less than 1 Watt of power.
- 15. (original) The method of claim 7, wherein the sample comprises a fatty ester, triglyceride, wax, oil, polyunsaturated fat, fatty alcohol, phenol, dipicolinic acid, carboxylic acid-containing molecule, alkaloidal narcotic, drug, drug metabolite, or herbicide.
- 16. (original) The method of claim 7, wherein the sample comprises a fatty acid or a mixture containing fatty acids.

- 17. (original) The method of claim 8, wherein the reagent chemical comprises a methylation reagent.
- 18. (original) The method of claim 17, wherein the reagent chemical comprises tetramethylammonium acetate, trimethylphenylammonium hydroxide, phenyl-trimethylammonium fluoride, N,N-Dimethylformamide dimethyl acetal, or (m-trifluoro-methylphenyl) trimethylammonium hydroxide.
- 19. (original) The method of claim 17, wherein the reagent chemical comprises tetramethylammonium hydroxide.
- 20. (original) The method of claim 7, wherein the vapor is formed by pyrolysis, heated chemistry, or thermal desorption of the sample.
- 21. (withdrawn) A portable analyzer for the chemical analysis of a liquid or solid sample, comprising:

a micropyrolyzer for heating the sample to produce a vapor having at least one chemical species, and

- a chemical detector for detection of the at least one chemical species in the vapor.
- 22. (withdrawn) The portable analyzer of claim 21, further comprising a chemical preconcentrator for sorption of the vapor from the micropyrolyzer and release of the sorbed vapor.
- 23. (withdrawn) The portable analyzer of claim 22, further comprising a chemical separator for separation of the at least one chemical species in the released vapor.
- 24. (withdrawn) The portable analyzer of claim 21, further comprising a chemical separator for separation of the at least one chemical species in the vapor from the micropyrolyzer.
- 25. (withdrawn) The portable analyzer of claim 21, wherein the micropyrolyzer further comprises:

a substrate having a suspended membrane formed thereon, the membrane having a top side facing the substrate for accepting the sample; and

a resistive heating element disposed on the membrane such that the sample will be vaporized upon heating of the membrane by the resistive heating element.

- 26. (withdrawn) The portable analyzer of claim 25, wherein the substrate is selected from the group consisting of semiconductors and dielectrics.
- 27. (withdrawn) The portable analyzer of claim 26, wherein the substrate comprises silicon.
- 28. (withdrawn) The portable analyzer of claim 25, wherein the membrane comprises a material selected from the group consisting of silicon nitride, polysilicon, silicon oxynitride and silicon carbide.
- 29. (withdrawn) The portable analyzer of claim 25, wherein the resistive heating element comprises a circuitous metal trace.
- 30. (withdrawn) The portable analyzer of claim 29, wherein the metal comprises a metal selected from the group consisting of platinum, molybdenum, titanium, chromium, palladium, gold, tungsten, and combinations thereof.
- 31. (withdrawn) The portable analyzer of claim 23, wherein the chemical separator comprises a gas chromatograph column.
- 32. (withdrawn) The portable analyzer of claim 24, wherein the chemical separator comprises a gas chromatograph column.
- 33. (withdrawn) The portable analyzer of claim 21, wherein the chemical detector comprises a surface acoustic wave detector, mass spectrometer, spectrophotometer, flame ionization detector, or thermal conductivity detector.
- 34. (new) The method of claim 7 wherein the substrate is selected from the group consisting of semiconductors and dielectrics.
- 35. (new) The method of claim 34, wherein the substrate comprises silicon.
- 36. (new) The method of claim 7, wherein the membrane comprises a material selected from the group consisting of silicon nitride, polysilicon, silicon oxynitride and silicon carbide.

- 37. (new) The method of claim 7, wherein the resistive heating element comprises a circuitous metal trace.
- 38. (new) The method of claim 37, wherein the metal comprises a metal selected from the group consisting of platinum, molybdenum, titanium, chromium, palladium, gold, tungsten, and combinations thereof.